



SPW

DOCKET: FIS920020157US1

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

INVENTOR: Ricky S. Amos et al.) EXAMINER: Olivia T. Luk
SERIAL NO.: 10/605,261) ART UNIT: 2812
FILING DATE: September 18, 2003) DATE: 7 March 2005
FOR: PROCESS OPTIONS FOR FORMING SILICIDED METAL GATES FOR
ADVANCED CMOS DEVICES

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Responsive to the Restriction Requirement Office Action mailed February 14, 2005, Applicants provisionally elect the subject matter of Group I, claims 1-6, for examination herein.